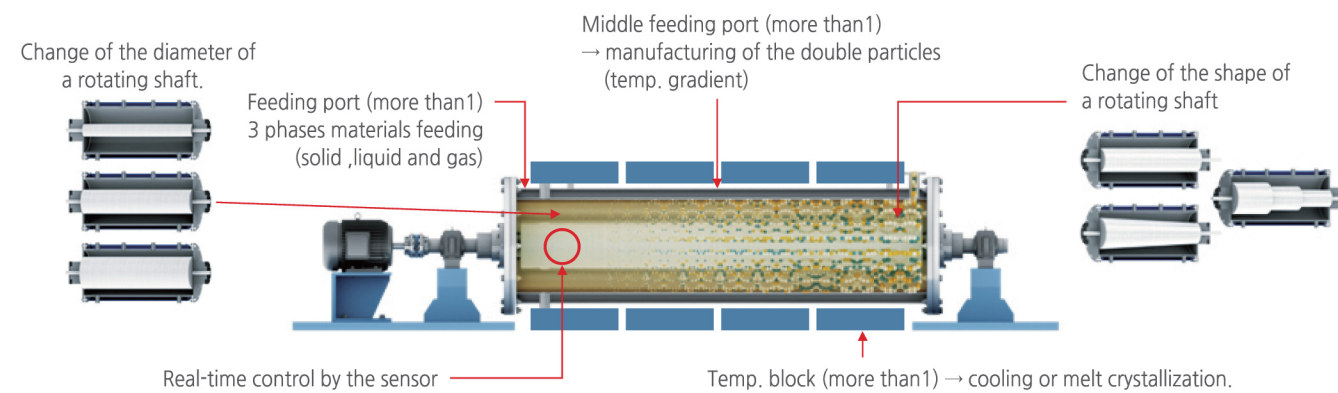


LCTR® series



Option



Slurry feeding pump

Max 600 rpm
Max 8 bar



Solution feeding pump (for production)

Max 200 L/min
Max 16 bar
Materials : PTFE



Electronic scale (for confirming the feeding quantity)

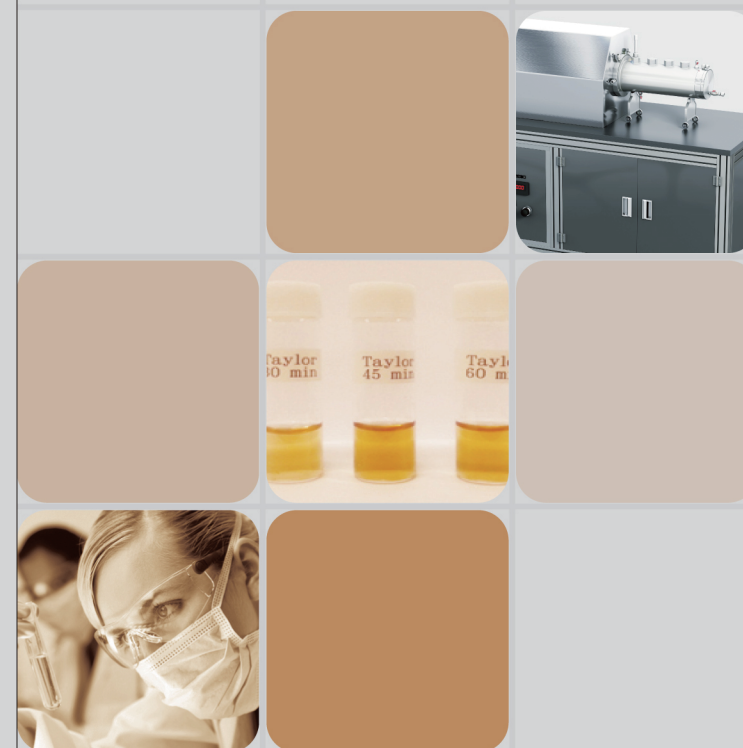
Alternative to a flow-meter
0.01 ~ 10 kg
0.001 ~ 1 kg



Bath circulator

Controlling reaction temp.
-25 ~ 150 °C

Productivity improvement and the control of explosive reaction



Manufacturing equipment of Graphene Oxide



#209, 27, Dunchon-daero 457beon-gil, Jungwon-gu, Seongnam-si, Gyeonggi-do, Korea
Tel. +82-31-737-2375 Fax. 82-31-737-2757 E-mail. laminar@laminarm.co.kr
www.laminarm.com

LCTR[®]-tera 3100



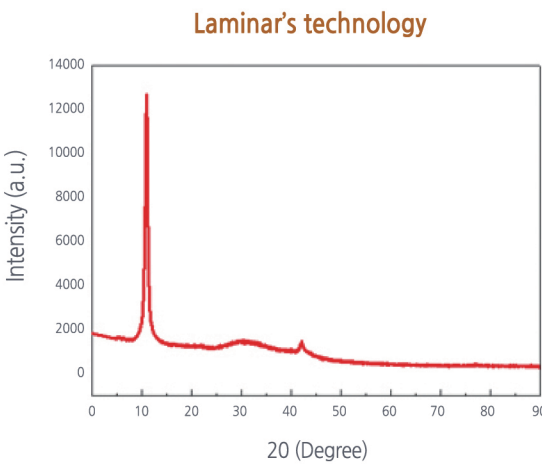
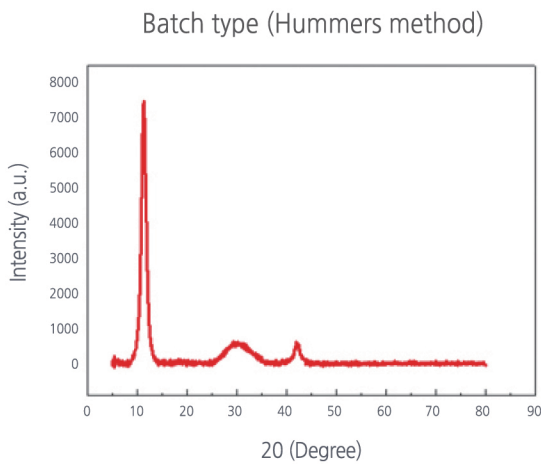
Characteristics of LCTR[®]-tera3100

- Just max. one hour needs to manufacture Graphene oxide instead of 5 days required from the conventional Hummers method, due to highly improvement of intercalation speed between layers by strong forced Taylor fluid flow.
- Controlling explosive reaction in safety
- Working at Room temperature for production
- Continuous Graphene Oxide manufacturing system

Specification of LCTR[®]-tera3100

Working volume (L)	1
Reaction temp. (°C)	Max 40
Rotation speed (rpm)	Max 1500
Material	Hastelloy-C, Teflon
Dimension L/W/H (mm)	1470 * 700 * 1150
Weight (kg)	500

XRD data



Batch type (Hummers method)



5 days (R.T.) or 18 hrs. (35°C)

Laminar's technology



under 1 hrs. (R.T.)

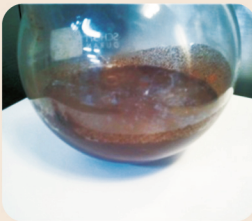
Hummers method - batch type process



Graphite + KMnO₄ +
NaNO₃ + H₂SO₄



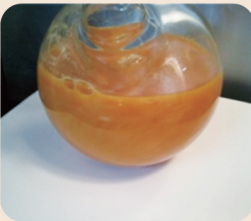
After 2 hours



After 5 days

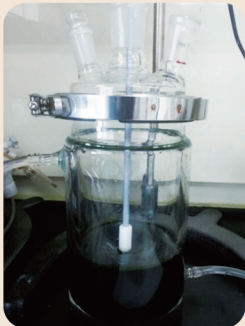
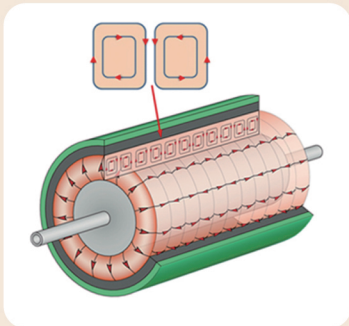


5 wt% H₂SO₄ addition

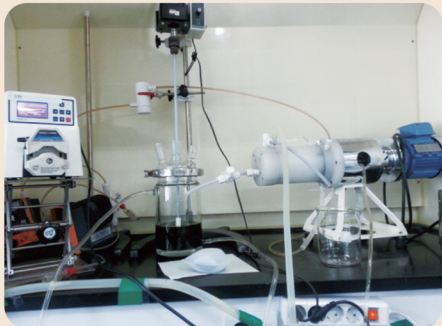


H₂O₂ addition

Taylor flow method - continuous process



Graphite + KMnO₄ +
NaNO₃ + H₂SO₄



After 1 hours



H₂O₂ addition